## BIAS GENERATION HAVING ADJUSTABLE RANGE AND RESOLUTION THROUGH METAL PROGRAMMING

## **ABSTRACT OF THE INVENTION**

The present invention uses metal programming to facilitate modifying a range and/or resolution of a bias voltage output signal generated by a programmable bias generator. A metal-programmable (MP) bias generator includes a MP transistor in the bias generator. The MP transistor includes either or both of a MP pull-up transistor and a MP pull-down transistor, each having a respective ON state resistance. A method of modifying the bias generator includes metal programming either or both of the MP pull-up transistor and the MP pull-down transistor, such that the respective ON state resistance of the corresponding metal-programmed transistor is combined with an effective ON state resistance of circuitry of the bias generator. The combined ON state resistances change one or both of the range and the resolution of a set of available magnitudes of the bias voltage output signal.

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